

Appl. No.: 10/087,484  
Amdt. Dated: July 15, 2004  
Reply to Office Action of: April 30, 2004

**Amendments to the Specification:**

Please replace the paragraph [0002] with the following amended paragraph:

[0002] The subject invention is directed generally to an excimer laser; and in particular to an excimer laser having a first or primary laser beam and a second or secondary laser beam suitable for annealing optical components.